IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Naoki MAKITA et al.

Serial No.: Currently unknown

Filing Date: Concurrently herewith

For: SEMICONDUCTOR FILM, METHOD FOR MANUFACTURING SEMICONDUCTOR FILM,

SEMICONDUCTOR DEVICE, AND METHOD FOR .

MANUFACTURING SEMICONDUCTOR DEVICE

INFORMATION DISCLOSURE STATEMENT

U.S. Patent and Trademark Office 2011 South Clark Place Customer Window, Mail Stop <u>PATENT APPLICATION</u> Crystal Plaza Two, Lobby, Room 1B03 Arlington, VA 22202

Sir:

In accordance with 37 CFR §1.56, and in recognition of their duty to disclose to the United States Patent and Trademark Office relevant information known to be material to patentability, Applicant herewith submits copies of the prior art listed on the attached Information Disclosure Statement (Form PTO-1449), including an English abstract. The statement is not a representation that all of the information cited is necessarily effective as prior art against the application.

Information Disclosure Statement November 3, 2003 Page 2 of 2

Applicant respectfully requests that the disclosed references be made of record in the subject application.

Respectfully submitted,

Date: November 3, 2003

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Substitute for form 1449/PTO

INFORMATION DISCLOSURE
STATEMENT BY APPLICANT

(Use as many sheets as necessary)

Complete if Known

Application Number

Filing Date
First Named Inventor
Art Unit

Examiner Name

Attorney Docket Number 70404.10

of

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U.S. PATENT DOCUMENTS									
Examiner. Initials*	Cite No. ¹	Document Number Number-Kind Code ^{2(if known)}	Publication Date MM -YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear				
	1	5,879,974	03/1999	Yamazaki					
	2	5,915,174	06/1999	Yamazaki et al.					
	3	6,251,712	06/2001	Tanaka et al.					

FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	Foreign Patent Document Country Code ³ Number-Kind Code ⁵ (if known)	Publication Date MM -YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Le	
	4	JP 10-270363	10/1998	JAPAN		x	
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Examiner	Date	
Signature	Considered	

^{*}Examiner: Initial if reference considered, whether of not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered, include copy of this form with next communication to applicant.

¹ Applicant unique citation designation number (optional). ²See Kind Codes of USPTO Patent documents at www.uspto.gov or MPEP 901.04. ³ Enter Office that issued the document by the two-letter code (WIPO Strandard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English language Abstract is attached. This collection of information is required by 37 CFR 1.97 and 1.98. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14.